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(54) **ORGANIC LIGHT-EMITTING DISPLAY
DEVICE**

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ABSTRACT

An organic light-emitting display device includes: a substrate, light-emitting elements on the substrate, and a light control layer structure between an anode of each of the light-emitting elements and the substrate, the light control layer structure including at least one pair of an alternately stacked low refractive index layer and high refractive index layer, a lowest high refractive index layer contacting an upper surface of the substrate.

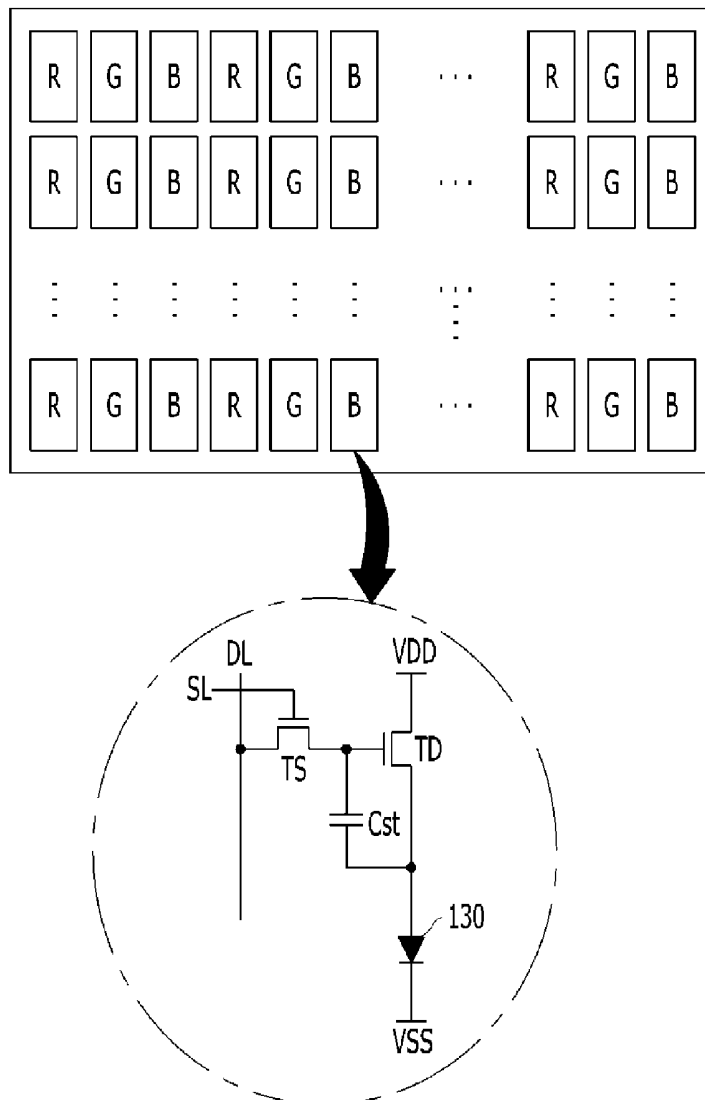


FIG. 1

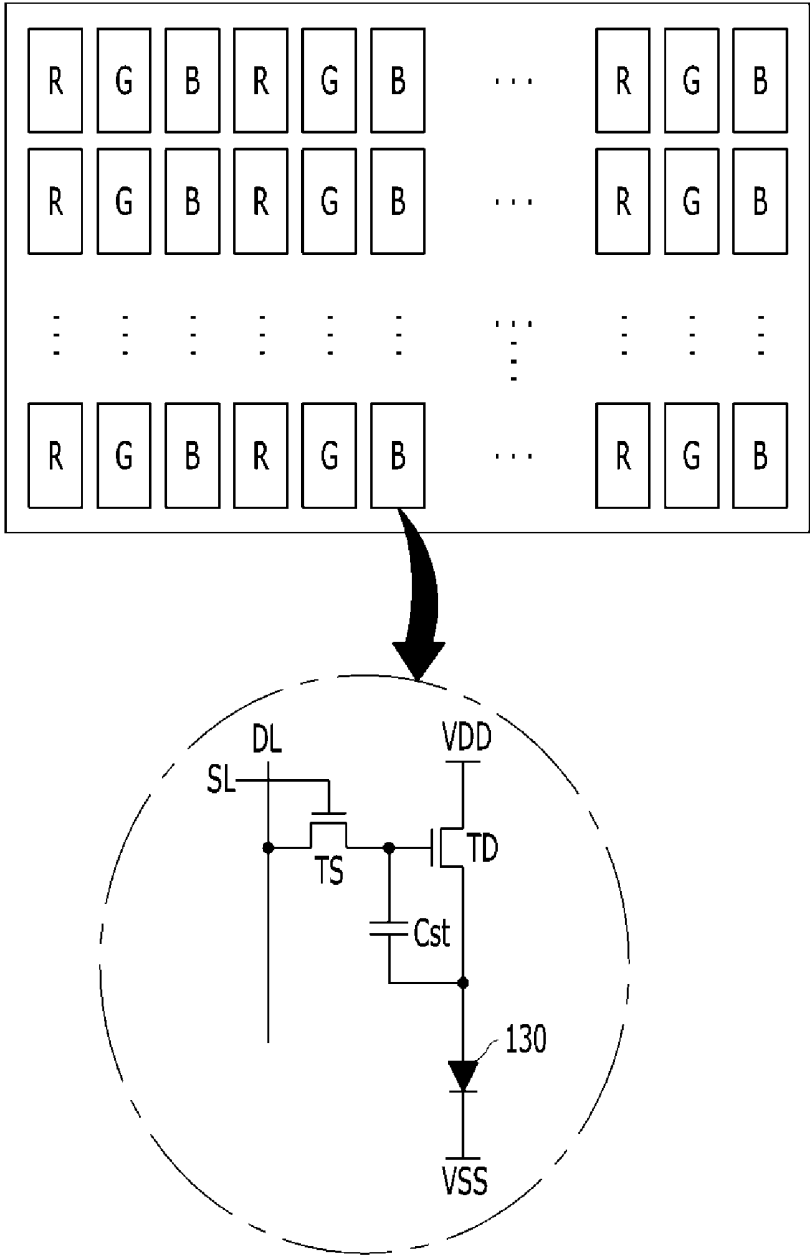


FIG. 2

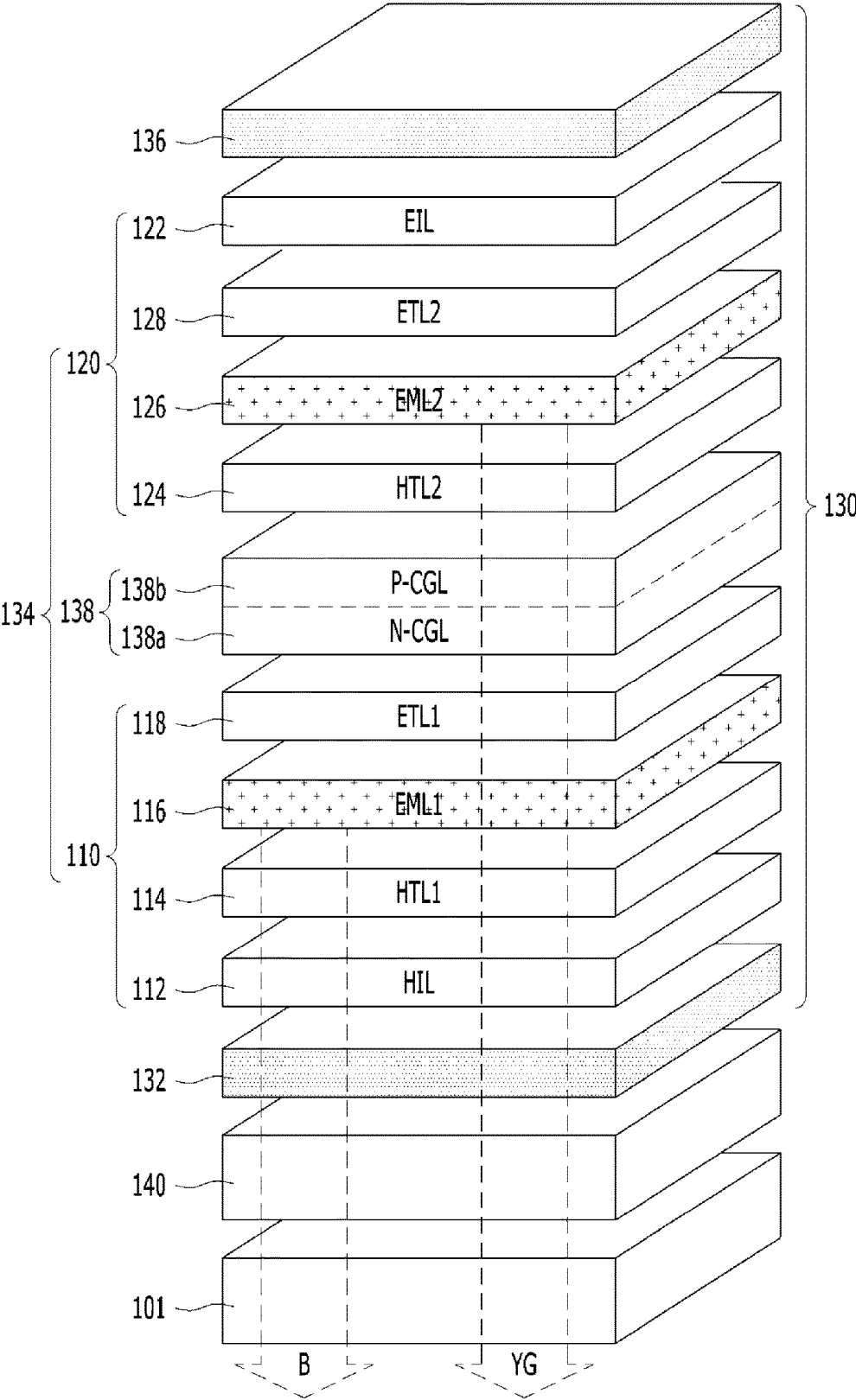


FIG. 4

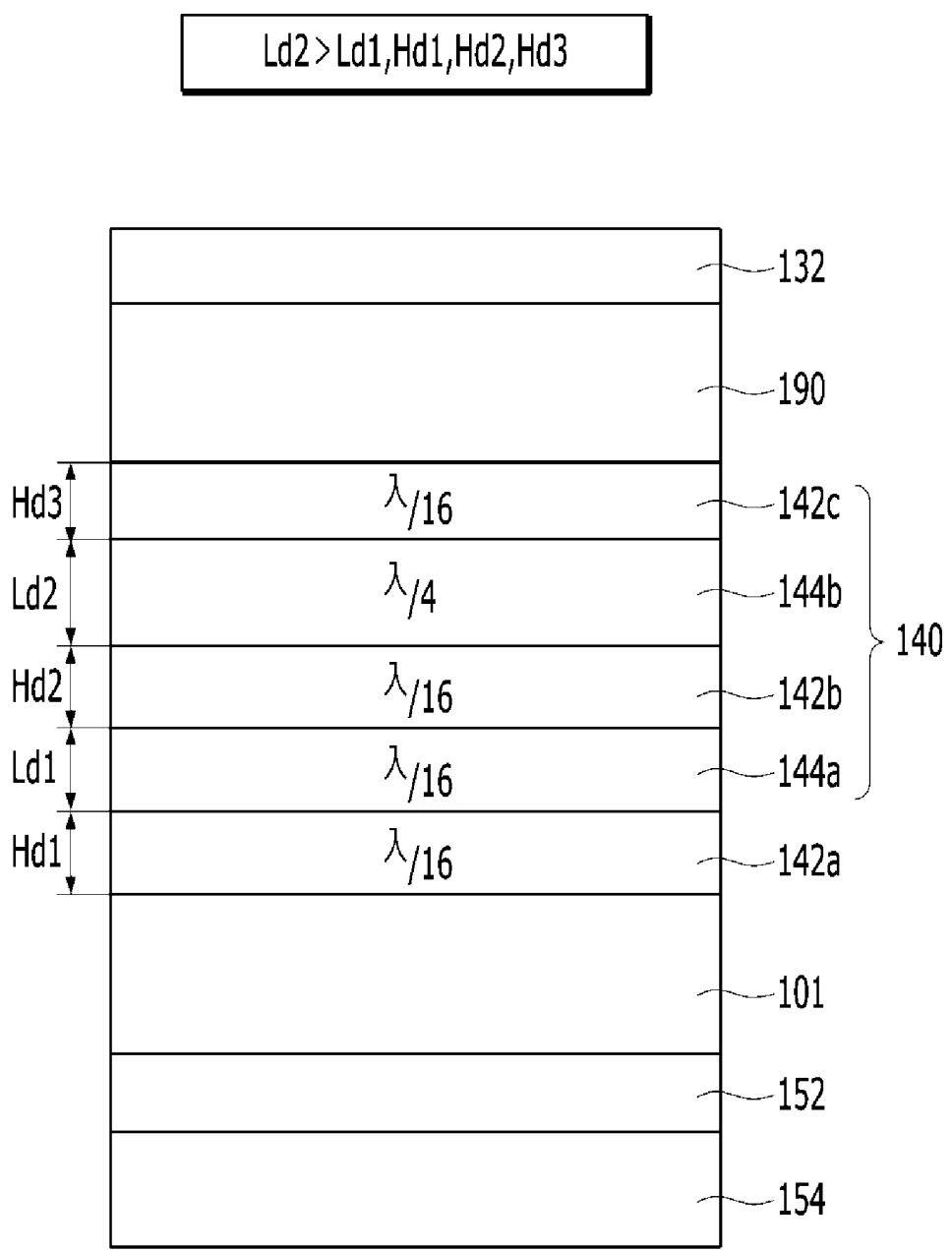


FIG. 5A

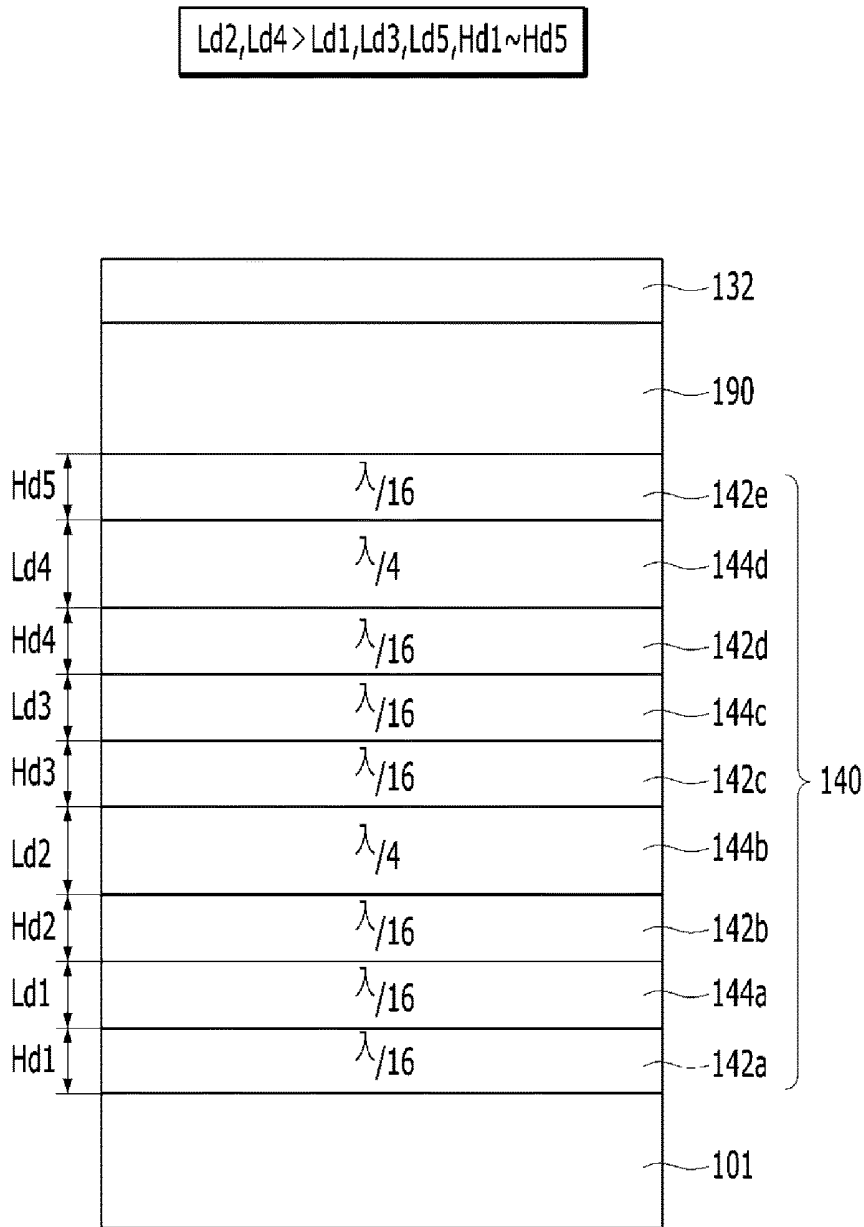


FIG. 5B

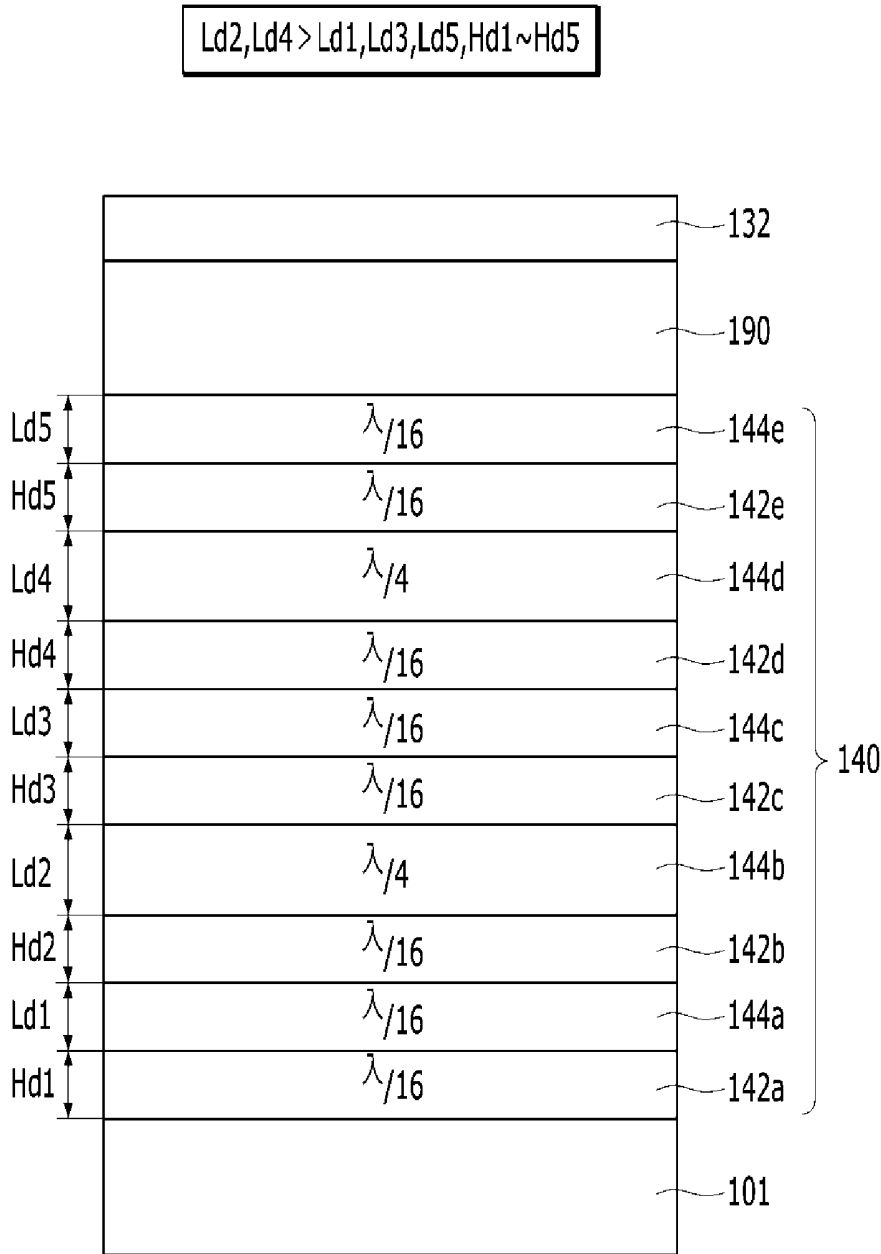
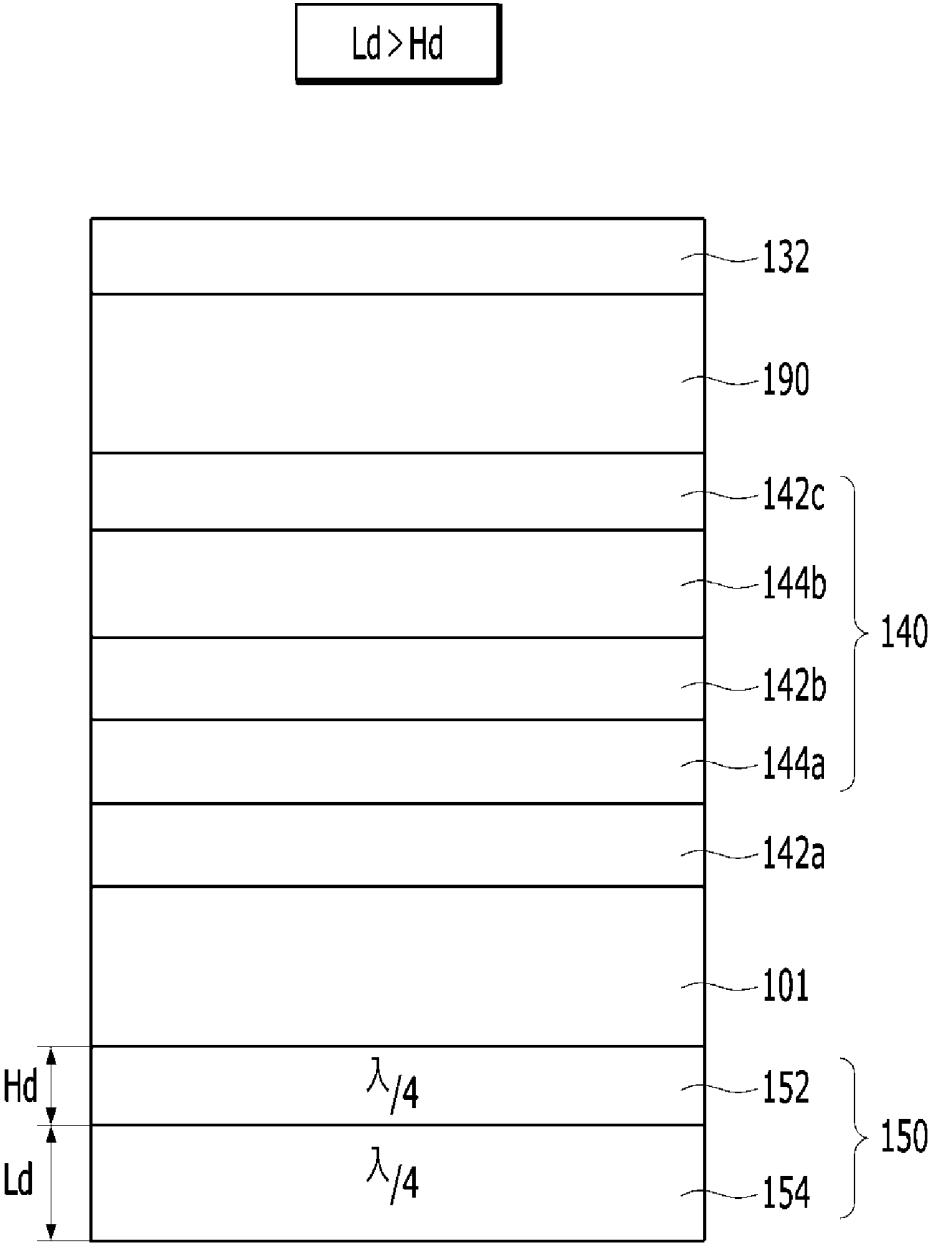


FIG. 6



ORGANIC LIGHT-EMITTING DISPLAY DEVICE

CROSS-REFERENCE TO RELATED APPLICATION(S)

[0001] This application claims the priority of Korean Application No. 10-2016-0172770, filed on Dec. 16, 2016, the entirety of which is hereby incorporated by reference.

BACKGROUND

1. Technical Field

[0002] The present disclosure relates to an organic light-emitting display device, and more particularly, to an organic light-emitting display device having improved efficiency.

2. Discussion of the Related Art

[0003] As we have recently entered the information age, the field of displays that visually display electrical information signals has been rapidly developed. To satisfy such development, various flat display devices having excellent performance, such as thinness, light weight, and low power consumption, are now being vigorously developed. As examples of flat display devices, there are a liquid crystal display (LCD), a plasma display panel (PDP), a field emission display (FED), an organic light-emitting display, etc.

[0004] Particularly, an organic light-emitting display is a self-luminous display and has advantages as compared with other flat displays, such as high response speed, high luminous efficacy, high brightness, and wide viewing angle. Such an organic light-emitting display includes an anode, a hole injection layer, a hole transport layer, a light-emitting layer, an electron transport layer, an electron injection layer, and a cathode.

[0005] In the organic light-emitting display, light generated by the light-emitting layer exits through a substrate. Thus, an image is displayed. However, light generated by the light-emitting layer is reflected at an interface between the anode and the substrate toward the cathode due to a refractive index difference therebetween. Thus, efficiency may be lowered.

SUMMARY

[0006] Accordingly, the present disclosure is directed to an organic light-emitting display device that substantially obviates one or more of the problems due to limitations and disadvantages of the related art.

[0007] An aspect of the present disclosure is to provide an organic light-emitting display device having improved efficiency.

[0008] Additional features and aspects will be set forth in the description that follows, and in part will be apparent from the description, or may be learned by practice of the inventive concepts provided herein. Other features and aspects of the inventive concepts may be realized and attained by the structure particularly pointed out in the written description, or derivable therefrom, and the claims hereof as well as the appended drawings.

[0009] To achieve these and other aspects of the inventive concepts as embodied and broadly described, there is provided an organic light-emitting display device, including: a substrate, light-emitting elements on the substrate, and a light control layer structure between an anode of each of the

light-emitting elements and the substrate, the light control layer structure including at least one pair of an alternately stacked low refractive index layer and high refractive index layer, a lowest high refractive index layer contacting an upper surface of the substrate.

[0010] Other systems, methods, features and advantages will be, or will become, apparent to one with skill in the art upon examination of the following figures and detailed description. It is intended that all such additional systems, methods, features and advantages be included within this description, be within the scope of the present disclosure, and be protected by the following claims. Nothing in this section should be taken as a limitation on those claims. Further aspects and advantages are discussed below in conjunction with the embodiments of the disclosure. It is to be understood that both the foregoing general description and the following detailed description of the present disclosure are examples and explanatory, and are intended to provide further explanation of the disclosure as claimed.

BRIEF DESCRIPTION OF THE DRAWINGS

[0011] The accompanying drawings, that are included to provide a further understanding of the disclosure and are incorporated in and constitute a part of this application, illustrate embodiments of the disclosure and together with the description serve to explain various principles of the disclosure.

[0012] FIG. 1 is a plan view of an organic light-emitting display device in accordance with an embodiment of the present disclosure.

[0013] FIG. 2 is a cross-sectional view illustrating a light-emitting element shown in FIG. 1 in detail.

[0014] FIG. 3 is a cross-sectional view illustrating a driving thin film transistor connected to the light-emitting element shown in FIG. 2 in detail.

[0015] FIG. 4 is a cross-sectional view illustrating an example of a light control layer structure shown in FIG. 2.

[0016] FIGS. 5A and 5B are cross-sectional views of additional examples of the light control layer structure shown in FIG. 2.

[0017] FIG. 6 is a cross-sectional view of an organic light-emitting display device according to an embodiment including a second light control layer structure.

[0018] Throughout the drawings and the detailed description, unless otherwise described, the same drawing reference numerals should be understood to refer to the same elements, features, and structures. The relative size and depiction of these elements may be exaggerated for clarity, illustration, and convenience.

DETAILED DESCRIPTION

[0019] Reference will now be made in detail to some embodiments of the present disclosure, examples of that may be illustrated in the accompanying drawings. In the following description, when a detailed description of well-known functions or configurations related to this document is determined to unnecessarily cloud a gist of the inventive concept, the detailed description thereof will be omitted. The progression of processing steps and/or operations described is an example; however, the sequence of steps and/or operations is not limited to that set forth herein and may be changed as is known in the art, with the exception of steps and/or operations necessarily occurring in a particular order.

Like reference numerals designate like elements throughout. Names of the respective elements used in the following explanations are selected only for convenience of writing the specification and may be thus different from those used in actual products.

[0020] In the description of embodiments, when a structure is described as being positioned “on or above” or “under or below” another structure, this description should be construed as including a case in which the structures contact each other as well as a case in which a third structure is disposed therebetween.

[0021] FIG. 1 is a plan view of an organic light-emitting display device in accordance with an embodiment of the present disclosure. FIG. 2 is a cross-sectional view illustrating a light-emitting element shown in FIG. 1 in detail. FIG. 3 is a cross-sectional view illustrating a driving thin film transistor connected to the light-emitting element shown in FIG. 2 in detail. FIG. 4 is a cross-sectional view illustrating an example of a light control layer structure shown in FIG. 2.

[0022] The organic light-emitting display device shown in the FIG. 1 example may display an image through unit pixels including light-emitting elements 130. The unit pixels may include red (R), green (G), and blue (B) sub-pixels, or may include red (R), green (G), blue (B), and white (W) sub-pixels. Each sub-pixel may include the light-emitting element 130 and a pixel driving circuit to independently drive the light-emitting element 130.

[0023] The light-emitting element 130 may include an anode 132 and a cathode 136 opposite each other, and a light-emitting stack 134 disposed between the anode 132 and the cathode 136, as shown in the FIG. 2 example. At least one of the anode 132 and the cathode 136 may be formed as a transmissive electrode. If the anode 132 is a transmissive electrode and the cathode 136 is a reflective electrode, the organic light-emitting display device may be a rear emission type light-emitting structure that may emit light through the lower part thereof. If the anode 132 is a reflective electrode and the cathode 136 is a transmissive electrode, the organic light-emitting display device may be a front emission type light-emitting structure that may emit light through the upper part thereof. Further, both the anode 132 and the cathode 136 may be formed as transmissive electrodes. Thus, the organic light-emitting display device may have a dual emission-type light-emitting structure that may emit light through the upper and lower parts thereof.

[0024] A transmissive electrode may use a transparent conductive material, such as indium tin oxide (ITO) and/or indium zinc oxide (IZO), and an opaque conductive material, such as aluminum (Al), gold (Au), molybdenum (Mo), chrome (Cr), copper (Cu), and/or LiF. A reflective electrode may use a reflective metal, such as aluminum (Al), gold (Au), molybdenum (Mo), chrome (Cr), copper (Cu), and/or LiF, or may have a multilayer structure using the same. A transmissive electrode may use a transparent conductive material, such as indium tin oxide (ITO) and/or indium zinc oxide (IZO). Embodiments are not limited to these examples.

[0025] In example embodiments of the present disclosure, the anode 132 as a transmissive electrode and the cathode 136 as a reflective electrode will be described. The light-emitting stack 134 may include a charge generation layer 138 and first and second light-emitting stacks 110 and 120 opposite each other, with the charge generation layer 138

interposed therebetween. The charge generation layer 138 may include an N-type charge generation layer (N-CGL) 138a and a P-type charge generation layer (P-CGL) 138b, which may be sequentially stacked.

[0026] The P-type charge generation layer 138b may be between the N-type charge generation layer 138a and a second hole transport layer 124, and may generate holes and electrons. Holes generated by the P-type charge generation layer 138b may be injected into the second hole transport layer 124 of the neighboring second light-emitting stack 120. Electrons generated by the P-type charge generation layer 138b may be injected into the N-type charge generation layer 138a. The N-type charge generation layer 138a may be between the P-type charge generation layer 138b and a first electron transport layer 118, and may inject and transport electrons injected from the P-type charge generation layer 138b into the first electron transport layer 118.

[0027] The first light-emitting stack 110 may be between the anode 132 and the N-type charge generation layer 138a. The first light-emitting stack 110 may include a hole injection layer (HIL) 112, at least one first hole transport layer (HTL1) 114, a first light-emitting layer (EML1) 116, and a first electron transport layer (ETL1) 118, which may be sequentially formed on the anode 132. The first hole transport layer 114 may supply holes from the anode 132 to the first light-emitting layer 116, and the first electron transport layer 118 may supply electrons from the N-type charge generation layer 138a to the first light-emitting layer 116. In the first light-emitting layer 116, the holes supplied through the first hole transport layer 114 and the electrons supplied through the first electron transport layer 118 may recombine with each other to generate light.

[0028] The second light-emitting stack 120 may be between the cathode 136 and the P-type charge generation layer 138b. The second light-emitting stack 120 may include a second hole transport layer (HTL2) 124, a second light-emitting layer (EML2) 126, a second electron transport layer (ETL2) 128, and an electron injection layer (EIL) 122, which may be sequentially formed on the P-type charge generation layer 138b. The second hole transport layer 124 may supply holes from the P-type charge generation layer 138b to the second light-emitting layer 126, and the second electron transport layer 128 may supply electrons from the cathode 136, injected through the electron injection layer 122, to the second light-emitting layer 126. In the second light-emitting layer 126, the holes supplied through the second hole transport layer 124 and the electrons supplied through the second electron transport layer 128 may recombine with each other to generate light.

[0029] For example, the first light-emitting layer 116 may include a blue fluorescent or phosphorescent dopant and a host, and may thus emit blue light, and the second light-emitting layer 126 may include a yellowish-green fluorescent or phosphorescent dopant and a host, and may thus emit yellowish-green light, thereby generating white light. In addition, white light may be generated using other fluorescent or phosphorescent dopants.

[0030] A color filter 182 may be disposed on a protective film 178 to overlap an emission area prepared by a bank 184, as shown in the FIG. 3 example. Any one of red (R), green (G), and blue (B) color filters 182 may be disposed in each sub-pixel. That is, a red (R) color filter 182 may be disposed in a red (R) sub-pixel, a green (G) color filter 182 may be disposed in a green (G) sub-pixel, and a blue (B) color filter

182 may be disposed in a blue (B) sub-pixel. Therefore, white light generated by the light-emitting stack **134** may pass through the color filter **182**. Thus, light of a color corresponding to the color filter **182** may be produced. Further, the color filter **182** may extend to cover at least one of switching and driving thin film transistors TS and TD.

[0031] As such, if the light-emitting stack **134** generates white light, white light generated by the light-emitting stack **134** may be incident upon the color filter **182**, thus implementing a color image. On the other hand, each light-emitting stack **134** may generate light of a color corresponding to each sub-pixel without the color filter **182**. Thus, a color image may be implemented. That is, the light-emitting stack **134** of a red sub-pixel may generate red light, the light-emitting stack **134** of a green sub-pixel may generate green light, and the light-emitting stack **134** of a blue sub-pixel may generate blue light.

[0032] The pixel driving circuit may include a switching thin film transistor TS, a driving thin film transistor TD, and a storage capacitor Cst. The switching thin film transistor TS may be turned on when a scan pulse is supplied to a scan line SL, and may supply a data signal supplied to a data line DL to the storage capacitor Cst and a gate electrode of the driving thin film transistor TD.

[0033] The driving thin film transistor TD may control a current (I) supplied from a high voltage (VDD) supply line to the light-emitting element **130** in response to the data signal supplied to the gate electrode of the driving thin film transistor TD, thus adjusting an amount of light emitted from the light-emitting element **130**. Further, even if the switching thin film transistor TS were to be turned off, the driving thin film transistor TD may supply a constant current (I) due to voltage charged in the storage capacitor Cst until a data signal of a next frame is supplied, and thus may maintain emission of light from the light-emitting element **130**. A low voltage (VSS) supply line, which may be low or a ground potential, may also be provided.

[0034] As such, the driving thin film transistor TD may include a gate electrode **102**, a source electrode **108**, a drain electrode **106**, and an active layer **104**, as shown in the FIG. 3 example. The gate electrode **102** may be formed on a gate insulating pattern **172** having the same shape as the gate electrode **102**. The gate electrode **102** may overlap a channel area of the active layer **104** with the gate insulating pattern **172** interposed therebetween. The source electrode **108** may be connected to the active layer **104** exposed through a source contact hole SH formed through an interlayer insulating film **176**. The drain electrode **106** may be connected to the active layer **104** exposed through a drain contact hole DH formed through the interlayer insulating film **176**. Further, the drain electrode **106** may be exposed through a pixel contact hole PH formed through a protective film **178** and a planarization film **180**, and may thus be connected to the anode **132**.

[0035] Each of the gate electrode **102**, the source electrode **108**, and the drain electrode **106** may have a single-layer structure including, for example, molybdenum (Mo), aluminum (Al), chrome (Cr), gold (Au), titanium (Ti), nickel (Ni), neodymium (Nd), copper (Cu), and/or an alloy thereof, or may have a multilayer structure including the same, but embodiments are not limited thereto. The active layer **104** may overlap the gate electrode **102** with the gate insulating pattern **172** interposed therebetween, and may thus form a channel between the source and drain electrodes **108** and

106. The active layer **104** may include at least one of: an amorphous semiconductor material, a polycrystalline semiconductor material, and an oxide semiconductor material.

[0036] A buffer film **174**, a light shielding layer **170**, and a light control layer structure **140** may be formed between the active layer **104** and the substrate **101**. The light shielding layer **170** may be on the light control layer structure **140** and may overlap the active layer **104**. The light shielding layer **170** may absorb or reflect light incident from the outside, and may thus block external light incident upon the active layer **104**. The light shielding layer **170** may be formed of an opaque metal, such as Mo, Ti, Al, Cu, Cr, Co, W, Ta, and/or Ni. The buffer film **174** may reduce or prevent diffusion of moisture or impurities generated from the substrate **101**, or may adjust a heat transfer speed during crystallization, thus facilitating crystallization of the active layer **104**.

[0037] In the organic light-emitting display device, a refractive index layer of a thin film layer, disposed in the path of light generated from the light-emitting element **130** and traveling to the light control layer structure **140**, may be formed of a material having similar refractive indexes to low refractive index layers of the light control layer structure **140**. That is, the buffer film **174**, the interlayer insulating film **176**, the protective film **178**, the color filter **182**, and the planarization film **180**, which may be disposed between the anode **132** and the light control layer structure **140**, may be formed of materials having similar refractive indexes to the low refractive index layers of the light control layer structure **140**.

[0038] Further, the light control layer structure **140** may be disposed between the anode **132** and the substrate **101**. To reduce a refractive index difference between the anode **132** and substrate **101** having different refractive indexes, the light control layer structure **140** may be formed between the anode **132** and the substrate **101** to have a refractive index between the refractive indexes of the anode **132** and the substrate **101**. For example, if the substrate **101** has a refractive index of 1.5 and the anode **132** has a refractive index of 1.8 or more, the light control layer structure **140** may have a refractive index of 1.5~1.8.

[0039] For this purpose, the light control layer structure **140** may be formed by alternately stacking low refractive index layers **144a** and **144b** and high refractive index layers **142a**, **142b**, and **142c** having smaller physical thicknesses than those of the low refractive index layers **144a** and **144b**. For example, if the lowermost layer **142a** of the light control layer structure **140**, contacting the upper surface of the substrate **101**, has a high refractive index and a thin film layer **190**, between the anode **132** and the light control layer structure **140**, has a low refractive index, low reflection effects may be acquired. For this purpose, the thin film layer **190**, between the anode **132** and the light control layer structure **140**, may be formed of a material having a lower refractive index than the high refractive index layers **142a**, **142b**, and **142c** of the light control layer structure **140**. That is, the buffer film **174**, the interlayer insulating film **176**, the protective film **178**, the color filter **182**, and the planarization film **180**, which may be between the anode **132** and the light control layer structure **140**, may be formed of materials having similar refractive indexes to the low refractive index layers **144a** and **144b** of the light control layer structure **140**. The light control layer structure **140**, in which a first high refractive index layer **142a**, a first low refractive index layer

144a, a second high refractive index layer **142b**, a second low refractive index layer **144b**, and a third high refractive index layer **142c** may be sequentially stacked on the substrate **101**, will be described by examples.

[0040] The first and second low refractive index layers **144a** and **144b** may be formed of a material having a refractive index n_1 which may be greater than or equal to 1.3 and may be less than or equal to 1.6 (e.g., $1.3 \leq n_1 \leq 1.6$). For example, the first and second low refractive index layers **144a** and **144b** may be formed to have a single layer or multilayer structure using at least one of SiO_2 ($n_1=1.4$ -1.5) and MgF_2 ($n_1=1.3$ -1.4).

[0041] The first to third high refractive index layers **142a**, **142b**, and **142c** may be formed of a material having a refractive index n_2 which may be greater than or equal to 1.6 and may be less than or equal to 2.4 (e.g., $1.6 \leq n_2 \leq 2.4$). The first to third high refractive index layers **142a**, **142b**, and **142c** may be formed to have a single layer or multilayer structure using at least one of Si_3N_4 ($n_2=1.8$ -1.9), TiO_2 ($n_2=2.0$ -2.3), MgO ($n_2=1.74$), Al_2O_3 ($n_2=1.8$ -1.9), SiO ($n_2=1.8$ -1.9), and ZnS ($n_2=2.3$ -2.4).

[0042] The optical thicknesses of the respective layers of the light control layer structure **140** may be formed to be $\lambda/4i$ (where “ i ” is a natural number). For example, the first to third high refractive index layers **142a**, **142b**, and **142c** and the first low refractive index layer **144a** may have an optical thickness of $\lambda/16$, and the second low refractive index layer **144b** may have an optical thickness of $\lambda/4$, to control a phase difference of blue light generated by the first light-emitting layer **116**, and thus may raise blue light output efficiency. For example, when the wavelength of blue light generated by the first light-emitting layer **116** is 450 nm, the first to third high refractive index layers **142a**, **142b**, and **142c** having an optical thickness of $\lambda/6$ may have physical thicknesses Hd1 , Hd2 , and Hd3 of 14-16 nm, the first low refractive index layer **144a** having an optical thickness of $\lambda/16$ may be formed to have a first physical thickness Ld1 of 15-19 nm, and the second low refractive index layer **144b** having an optical thickness of $\lambda/4$ may be formed to have a second physical thickness Ld2 of 65-80 nm, which may be greater than that of at least one of the first to third high refractive index layers **142a**, **142b**, and **142c** and the first low refractive index layer **144a**. For example, an optical thickness $\lambda/4i$ may be equal to a refractive index n multiplied by a physical thickness d . All numerical examples above are nonlimiting.

[0043] FIGS. 5A and 5B are cross-sectional views of additional examples of the light control layer structure shown in FIG. 2.

[0044] The light control layer structure **140** may include six or more layers, as illustrated in the examples of FIGS. 5A and 5B. The light control layer structure **140** shown in the FIG. 5A example may include nine layers, e.g., a first high refractive index layer **142a**, a first low refractive index layer **144a**, a second high refractive index layer **142b**, a second low refractive index layer **144b**, a third high refractive index layer **142c**, a third low refractive index layer **144c**, a fourth high refractive index layer **142d**, a fourth low refractive index layer **144d**, and a fifth high refractive index layer **142e**, which may be sequentially formed on the substrate **101**. The light control layer structure **140** shown in the FIG. 5B example may include ten layers, e.g., a first high refractive index layer **142a**, a first low refractive index layer **144a**, a second high refractive index layer **142b**, a second low refractive index layer **144b**, a third high refractive index

layer **142c**, a third low refractive index layer **144c**, a fourth high refractive index layer **142d**, a fourth low refractive index layer **144d**, a fifth high refractive index layer **142e**, and a fifth low refractive index layer **144e**, which may be sequentially formed on the substrate **101**.

[0045] For example, the first to fifth high refractive index layers **142a**, **142b**, **142c**, **142d**, and **142e** and the first, third and fifth low refractive index layer **144a**, **144c**, and **144e** may have an optical thickness of $\lambda/16$. The second and fourth low refractive index layers **144b** and **144d** may have an optical thickness of $\lambda/4$. Therefore, when the wavelength of blue light generated by the first light-emitting layer **116** is 450 nm, the first to fifth high refractive index layers **142a**, **142b**, **142c**, **142d**, and **142e** having an optical thickness of $\lambda/16$ may have respective physical thicknesses Hd1 , Hd2 , Hd3 , Hd4 , and Hd5 of 14-16 nm, the first, third and fifth low refractive index layers **144a**, **144c**, and **144e** having an optical thickness of $\lambda/16$ may have respective physical thicknesses Ld1 , Ld3 , and Ld5 of 15-19 nm, and the second and fourth low refractive index layers **144b** and **144d** having an optical thickness of $\lambda/4$ may have respective physical thicknesses Ld2 and Ld4 of 65-80 nm. For example, the physical thickness of at least one of the second and fourth low refractive index layers **144b** and **144d** may be greater than that of at least one of the first to fifth high refractive index layers **142a**, **142b**, **142c**, **142d**, and **142e** and the first, third and fifth low refractive index layers **144a**, **144c**, and **144e**. All numerical examples above are nonlimiting.

[0046] Because light reflected by the upper surface of each of the layers of the light control layer structure **140**, and light reflected by the lower surface of each of the layers of the light control layer structure **140**, may interfere with each other and may thus be offset, reflection of light at the interface between the anode **132** and the substrate **101** may be reduced or prevented. Therefore, by the light control layer structure **140**, light generated by the first and second light-emitting layers **116** and **126** may not be reflected at the interface between the anode **132** and the substrate **101** toward the cathode **136**, and may be transmitted by the substrate **101**, and luminous efficacy may thus be improved.

[0047] FIG. 6 is a cross-sectional view of an organic light-emitting display device according to an embodiment including a second light control layer structure.

[0048] The organic light-emitting display device shown in FIG. 6 may have a substantially similar configuration as the organic light-emitting display device in accordance with the above-described examples, except that the organic light-emitting display device in accordance with this example further includes a second light control layer structure **150**.

[0049] To reduce a refractive index difference between a substrate **101** and an air layer on the lower surface of the substrate **101** having different refractive indexes, the second light control layer structure **150** may be between the substrate **101** and the air layer, and may have a refractive index between the refractive indexes of the substrate **101** and the air layer. For example, if the substrate **101** has a refractive index of 1.5 and the air layer has a refractive index of 1, the second light control layer structure **150** may have a refractive index of 1-1.5.

[0050] As such, the second light control layer structure **150** may be formed by alternately stacking a lower high refractive index layer **152** and a lower low refractive index layer **154** at least one time on the lower surface of the substrate **101**, as shown in the FIG. 6 example. Although this

example describes the second light control layer structure **150** as including two layers, e.g., the lower high refractive index layer **152** and the lower low refractive index layer **154**, the second light control layer structure **150** may include three or more layers, e.g., lower high refractive index layers **152** and lower low refractive index layers **154**, which may be alternately stacked. For example, if the uppermost layer **152** of the second light control layer structure **150** contacting the lower surface of the substrate **101** has a high refractive index and the lowermost layer **154** of the second light control layer structure **150** contacting the air layer has a low refractive index, low reflection effects may be acquired.

[0051] The lower low refractive index layer **154** may be formed of a material having a refractive index n_1 which may be greater than or equal to 1.3 and may be less than or equal to 1.6 (e.g., $1.3 \leq n_1 \leq 1.6$). For example, the lower low refractive index layer **154** may have a single layer or multilayer structure using at least one of SiO_2 ($n_1=1.4-1.5$) and MgF_3 ($n_1=1.3-1.4$). The lower high refractive index layer **152** may be formed of a material having a refractive index n_2 which may be greater than or equal to 1.6 and may be less than or equal to 2.4 (e.g., $1.6 \leq n_2 \leq 2.4$). The lower high refractive index layer **152** may have a single layer or multilayer structure using at least one of Si_3N_4 ($n_2=1.8-1.9$), TiO_2 ($n_2=2.0-2.3$), MgO ($n_2=1.74$), Al_2O_3 ($n_2=1.8-1.9$), SiO ($n_2=1.8-1.9$) and ZnS ($n_2=2.3-2.4$).

[0052] The optical thicknesses of the respective layers of the second light control layer structure **150** may be $\lambda/4i$ (where “i” is a natural number). For example, the lower high refractive index layer **152** and the lower low refractive index layer **154** may have an optical thickness of $\lambda/4$. For example, when the wavelength of blue light generated by the first

the first and second light-emitting layers **116** and **126** may not be reflected at the interface between the substrate **101** and the air layer toward the cathode **136**, and may be transmitted by the air layer, and luminous efficacy may thus be improved.

[0054] It may be confirmed from Table 1 below that organic light-emitting display devices including light control layer structures **140** and/or **150** in test examples have raised efficiencies and brightnesses of blue (B) light and yellowish-green (YG) light, as compared to an organic light-emitting display device of a comparative example that does not include a light control layer structure.

[0055] For example, in the organic light-emitting display device in test example 2, which includes the anode **132** including ITO and the light control layer structure **140**, brightness of blue (B) light is increased by 18% and brightness of yellowish-green (YG) light is increased by 7%, as compared to the organic light-emitting display device in the comparative example. Further, in the organic light-emitting display device in test example 4, which includes the anode **132** including IZO and the light control layer structure **140**, brightness of blue (B) light is increased by 25% and brightness of yellowish-green (YG) light is increased by 38%, as compared to the organic light-emitting display device in the comparative example. Further, in the organic light-emitting display devices in test examples 3 and 4, each of which includes the anode **132** including IZO and the light control layer structure **140**, efficiency and brightness of yellowish-green (YG) light are further increased, as compared to the organic light-emitting display devices in test examples 1 and 2, each of which includes the anode **132** including ITO and the light control layer structure **140**.

TABLE 1

	Brightness	Efficiency	CCT	Structure	Spectrum	
	(Cd/m ²)	(Cd/A)			B	YG
Comparative example	3113	77.8	7018	Substrate/anode(ITO)	1	1
Test example 1	3341	83.52	5731	Substrate/light control layer structure (10 layers)/anode (ITO)	1%	11%
Test example 2	3167	79.18	7055	Substrate/light control layer structure (5 layers)/anode (ITO)	18%	7%
Test example 3	4083	102.1	4788	Substrate/light control layer structure (10 layers)/anode (IZO)	2%	45%
Test example 4	3901	97.5	5911	Substrate/light control layer structure (5 layers)/anode (IZO)	25%	38%

light-emitting layer **116** is 450 nm, the lower high refractive index layer **152** having an optical thickness of $\lambda/4$ may have a physical thickness H_d of 50-60 nm, and the lower low refractive index layer **154** having an optical thickness of $\lambda/4$ may have a physical thickness L_d of 65-80 nm. For example, an optical thickness $\lambda/4i$ is equal to a refractive index n multiplied by a physical thickness d . All numerical examples above are nonlimiting.

[0053] Therefore, because light reflected by the upper surface of each of the layers of the second light control layer structure **150**, and light reflected by the lower surface of each of the layers of the second light control layer structure **150** may interfere with each other and may thus be offset, reflection of light at the interface between the substrate **101** and the air layer may be reduced or prevented. That is, by the second light control layer structure **150**, light generated by

[0056] Although two light-emitting stacks are used in the examples described herein, three or more light-emitting stacks may be used. As apparent from the above description, an organic light-emitting display device in accordance with an embodiment of the present disclosure may include a light control layer structure disposed between a substrate and an anode. By such a light control layer structure, light generated by first and second light-emitting layers may not be reflected at the interface between the anode and substrate toward a cathode, but may be transmitted by the substrate, and luminous efficacy may thus be improved.

[0057] It will be apparent to those skilled in the art that various modifications and variations may be made in the present disclosure without departing from the technical idea or scope of the disclosure. Thus, it may be intended that embodiments of the present disclosure cover the modifica-

tions and variations of the disclosure provided they come within the scope of the appended claims and their equivalents.

What is claimed is:

1. An organic light-emitting display device, comprising: a substrate; light-emitting elements on the substrate; and a light control layer structure between an anode of each of the light-emitting elements and the substrate, the light control layer structure comprising at least one pair of an alternately stacked low refractive index layer and high refractive index layer, a lowest high refractive index layer contacting an upper surface of the substrate.
2. The organic light-emitting display device of claim 1, wherein the light control layer structure has a refractive index between a refractive index of the anode and a refractive index of the substrate.
3. The organic light-emitting display device of claim 1, wherein the low refractive index layer has a greater thickness than a thickness of the high refractive index layer.
4. The organic light-emitting display device of claim 1, wherein the light control layer structure comprises, sequentially disposed on the substrate: a first high refractive index layer; a first low refractive index layer; a second high refractive index layer; a second low refractive index layer; and a third high refractive index layer.
5. The organic light-emitting display device of claim 4, wherein the second low refractive index layer has a greater thickness than a thickness of at least one of the first to third high refractive index layers and a thickness of the first low refractive index layer.
6. The organic light-emitting display device of claim 1, wherein the light control layer structure comprises, sequentially disposed on the substrate: a first high refractive index layer, a first low refractive index layer; a second high refractive index layer; a second low refractive index layer; a third high refractive index layer; a third low refractive index layer; a fourth high refractive index layer; a fourth low refractive index layer; a fifth high refractive index layer; and a fifth low refractive index layer.
7. The organic light-emitting display device of claim 6, wherein at least one of the second and fourth low refractive index layers has a greater thickness than a thickness of at least one of the first to fifth high refractive index layers and a thickness of the first, third and fifth low refractive index layers.
8. The organic light-emitting display device of claim 1, further comprising a second light control layer structure on a lower surface of the substrate and comprising at least one pair of an alternately stacked lower low refractive index layer and lower high refractive index layer.

9. The organic light-emitting display device of claim 8, wherein a lowest lower high refractive index layer contacts the lower surface of the substrate.

10. The organic light-emitting display device of claim 8, wherein:

the second light control layer structure is between the substrate and an air layer on the lower surface of the substrate; and

the second light control layer structure has a refractive index between a refractive index of the substrate and a refractive index of the air layer.

11. The organic light-emitting display device of claim 8, wherein the lower low refractive index layer has a greater thickness than a thickness of the lower high refractive index layer.

12. The organic light-emitting display device of claim 1, wherein each of the light-emitting elements comprises:

the anode;

a cathode opposite the anode; and

at least one light-emitting stack between the anode and the cathode,

wherein the anode comprises a transparent conductive material, and

wherein the cathode comprises a reflective conductive material.

13. The organic light-emitting display device of claim 12, wherein the at least one light-emitting stack comprises:

a first light-emitting stack on the anode, the first light-emitting stack comprising a blue light-emitting layer; and

a second light-emitting stack disposed between the first light-emitting stack and the cathode, the second light-emitting stack comprising a yellowish-green light-emitting layer.

14. The organic light-emitting display device of claim 12, further comprising at least one thin film layer between the light control layer structure and the anode, the at least one thin film layer having a lower refractive index than the high refractive index layer.

15. The organic light-emitting display device of claim 14, wherein the at least one thin film layer has a same refractive index as the low refractive index layer.

16. The organic light-emitting display device of claim 14, further comprising:

a thin film transistor connected to each of the light-emitting elements;

a buffer film between an active layer of the thin film transistor and the light control layer structure;

an interlayer insulating film between a gate electrode and a drain electrode of the thin film transistor;

a protective film on the thin film transistor; and

a planarization film between the protective film and the anode,

wherein the at least one thin film layer comprises at least one of: the buffer film, the interlayer insulating film, the protective film, and the planarization film.

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[标]申请(专利权)人(译)	乐金显示有限公司		
申请(专利权)人(译)	LG DISPLAY CO. , LTD.		
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摘要(译)

一种有机发光显示装置，包括：衬底，所述衬底上的发光元件以及每个所述发光元件的阳极与所述衬底之间的光控层结构，所述光控层结构包括至少一个一对交替堆叠的低折射率层和高折射率层，最低高折射率层接触衬底的上表面。

